

Electronic Supplementary Information

Title: **Base-amplifying silicone resins generating aliphatic secondary amines autocatalytically: synthesis, characterization and application to positive-working photoresists**

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Decomposition behaviour of films of polymer **1** containing 10 wt% of PBG

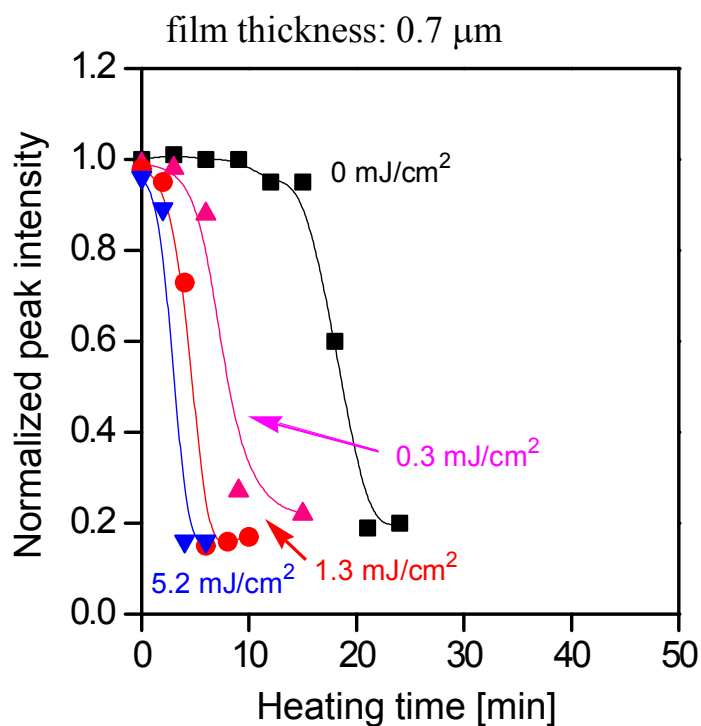


Fig. S1 Time course for the consumption of peak area of polymer **1** containing 10 wt% of PBG heated at 100 °C, with and without UV irradiation.